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2812
#4

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Calvin T. Gabriel et al.
Title: PROCESS FOR IMPROVING THE
ETCH STABILITY OF ULTRA-
THIN PHOTORESIST
Appl. No.: 09/819,552
Filing Date: 03/28/2001
Examiner: To be assigned
Art Unit: 2812

CERTIFICATE OF MAILING	
I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on the date below.	
<u>Roberta Cooper</u>	(Printed Name)
<u>Roberta Cooper</u>	(Signature)
<u>3/16/02</u>	(Date of Deposit)

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REQUEST TO RESCIND PREVIOUS NONPUBLICATION REQUEST

35 U.S.C. 122(b)(2)(B)(iii)

Commissioner for Patents
Washington, D.C. 20231

Sir:

Applicants hereby rescind the previous request that the above-identified application not be published under 35 U.S.C. 122(b).

Respectfully submitted,

Date

3-6-02

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